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09/825,611	04/03/2001	Sujit Sharan	95-0716.02	3508
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Charles Brantley Micron Technology, Inc.			EXAMINER	
Micron Techno 8000 S. Federal			KILDAY, LISA A	
Mail Stop 525 Boise, ID 837	16		ART UNIT	PAPER NUMBER
	• •		2829	
			DATE MAILED: 09/10/2003	

Please find below and/or attached an Office communication concerning this application or proceeding.

	Application No.	Applicant(s)	
	09/825,611	SHARAN ET AL.	
Office Action Summary	Examiner	Art Unit	
	Lisa A Kilday	2829	
The MAILING DATE of this communication Period for Reply	appears on the cover sheet	with the correspondence address	
A SHORTENED STATUTORY PERIOD FOR REITHE MAILING DATE OF THIS COMMUNICATION - Extensions of time may be available under the provisions of 37 CFR after SIX (6) MONTHS from the mailing date of this communication. - If the period for reply specified above is less than thirty (30) days, a - If NO period for reply is specified above, the maximum statutory per - Failure to reply within the set or extended period for reply will, by state - Any reply received by the Office later than three months after the material patent term adjustment. See 37 CFR 1.704(b). Status	N. t 1.136(a). In no event, however, may reply within the statutory minimum of t iod will apply and will expire SIX (6) Mutute, cause the application to become	a reply be timely filed nirty (30) days will be considered timely. DNTHS from the mailing date of this communication. ABANDONED (35 U.S.C. § 133).	
1) Responsive to communication(s) filed on <u>6</u>	03 April 2001 .		
2a) ☐ This action is FINAL . 2b) ☑	This action is non-final.		
Since this application is in condition for all closed in accordance with the practice unconsposition of Claims			i
4) Claim(s) 35-66 is/are pending in the applic	ation.		
4a) Of the above claim(s) is/are without	drawn from consideration.		
5) Claim(s) is/are allowed.			
6) Claim(s) is/are rejected.			
7) Claim(s) is/are objected to.			
8) Claim(s) <u>35-66</u> are subject to restriction and	d/or election requirement.		
Application Papers			
9) The specification is objected to by the Exam		Abo Evanos	
10) The drawing(s) filed on is/are: a) ac			
A, plicant may not request that any objection to 11) The proposed drawing correction filed on		disapproved by the Examiner.	
If approved, corrected drawings are required in		disapproved by the Examiner.	
12) The oath or declaration is objected to by the			
Priority under 35 U.S.C. §§ 119 and 120	Examino.		
13) Acknowledgment is made of a claim for fore	eian nriority under 35 U.S.C	: 8 119(a)-(d) or (f)	
a) ☐ All b) ☐ Some * c) ☐ None of	sign priority under 00 0.0.c	. 3 110(a) (a) 61 (i).	
1.☐ Certified copies of the priority docum	ents have been received		
2. ☐ Certified copies of the priority docum		Application No.	
3. Copies of the certified copies of the papplication from the International * See the attached detailed Office action for a	oriority documents have bed Bureau (PCT Rule 17.2(a)	en received in this National Stage	
14) Acknowledgment is made of a claim for dome	•		on).
a) ☐ The translation of the foreign language 15) ☐ Acknowledgment is made of a claim for dom	provisional application has	been received.	•
Attachment(s)	,,		
1) Notice of References Cited (PTO-892) 2) Notice of Draftsperson's Patent Drawing Review (PTO-948) 3) Information Disclosure Statement(s) (PTO-1449) Paper No(5) Notice	w Summary (PTO-413) Paper No(s) of Informal Patent Application (PTO-152)	

Art Unit: 2829

Election/Restrictions

Restriction to one of the following inventions is required under 35 U.S.C. 121:

- Claims 35-36, drawn to method of providing a CVD environment, classified in class 438, subclass 680.
- II. Claims 37-39, drawn to an atmosphere for a CVD process, classified in class 118, subclass 719.
- III. Claims 40-1, drawn to a plasma, classified in class 427, subclass 569.
- IV. Claims 42-66, drawn to a method of supporting a reaction between a precursor gas and a reactive gas, classified in class 430, subclass 5.

The inventions are distinct, each from the other because of the following reasons:

Inventions I and II are related as combination and subcombination. Inventions in this relationship are distinct if it can be shown that (1) the combination as claimed does not require the particulars of the subcombination as claimed for patentability, and (2) that the subcombination has utility by itself or in other combinations (MPEP § 806.05(c)). In the instant case, the combination as claimed does not require the particulars of the subcombination as claimed because if the CVD is a thermal CVD the subcombination is mutually exclusive. The subcombination has separate utility such as CVD and an atmosphere for thermal CVD cannot be used together.

Inventions I and III are related as combination and subcombination. Inventions in this relationship are distinct if it can be shown that (1) the combination as claimed does not require the particulars of the subcombination as claimed for patentability, and (2) that the subcombination has utility by itself or in other combinations (MPEP §

Page 3

Application/Control Number: 09/825,611

Art Unit: 2829

806.05(c)). In the instant case, the combination as claimed does not require the particulars of the subcombination as claimed because the plasma subcombination can be used together with thermal CVD. The subcombination has separate utility such as HDP CVD.

Inventions I and IV are related as combination and subcombination. Inventions in this relationship are distinct if it can be shown that (1) the combination as claimed does not require the particulars of the subcombination as claimed for patentability, and (2) that the subcombination has utility by itself or in other combinations (MPEP § 806.05(c)). In the instant case, the combination as claimed does not require the particulars of the subcombination as claimed because they are unrelated mutually exclusive subcombinations. The subcombination has separate utility such as it can support reactions in the secondary ion effect.

Species Restriction for Method Embodiments:

Applicant must choose from Group I-IV. If applicant elects group I or group IV, applicant must elect from the following species. Because these inventions are distinct for the reasons given above and have acquired a separate status in the art as shown by their different classification, restriction for examination purposes as indicated is proper.

This application contains claims directed to the following patentably distinct species of the claimed invention:

Species are defined by elements A-K below:

Applicant must choose an element from A-K:

A, Type of deposition:

Art Unit: 2829

- 1. CVD (¶ 3)
- 2. PECVD (¶4)
- 3. HDP CVD (¶8)
- B, Use of reaction promoter gas (¶44)
 - 1. Use of reaction promoter gas
 - 2. Without use of reaction promoter gas (skip to E1-2)

First Grouping:

If applicant chooses B1, choose from the element C-D:

- C, Type of reaction promoter gas (¶12)
 - 1. Adding a material that reduces the partial pressure contribution of at least one other gas reacting in said process
 - 2. Material is an inert gas, a noble gas
 - 3. Material is inert with respect to the current reaction, although it may be chemically active in other reactions
 - 4. Material chemically reacts with the other gases

If applicant chooses C2, choose from element D:

- \underline{D} , Type of noble gas ($\P 37$)
 - 1. Argon
 - 2. Helium
 - 3. Neon
 - 4. Krypton
 - 5. Xenon

Art Unit: 2829

- 6. Radon
- 7. Combinations of #D1-6

Second Grouping:

- \underline{E} , Type of layer depositing (¶2, 39)
 - 1. Metal and conductive films
 - 2. Insulating films (¶38)

If applicant chooses E1, choose from elements F-G:

- F, Type of metal/conductive film deposited (¶39):
 - 1. Aluminum
 - 2. Copper
 - 3. Aluminum-Copper alloys
 - 4. Tin
 - 5. Titanium
 - 6. Lead
 - 7. Titanium Tungsten alloys
 - 8. Tungsten
 - 9. Tungsten alloys
- \underline{G} , Metal source precursor (¶39):
 - 1. Organic
 - 2. Inorganic
- \underline{H} , Method of distributing deposition source gas (¶39):
 - 1. Gas phase

Art Unit: 2829

- 2. Liquid source converted to the gas phase through a bubbler system

 I. Parameters of the deposition (¶ 9, 40):
 - 1. IC HDP reactor
 - 2. No IC HDP reactor
- J, Other uses and alternative results for reaction-promoter gases (¶¶ 13, 42-43):
 - 1. Reactive sputtering/Self-sustained sputtering
 - 2. Plasma etching
 - 3. No other uses or alternative results

Optional specie:

Paragraph 43 on pg. 15 describes several embodiments of the current invention. The embodiments include: promoting, encouraging, fostering, assisting, aiding, advancing, cultivating, supporting, or otherwise participating in a chemical reaction for any plasma process. It is unclear whether all embodiments share the effects listed above. Or whether each embodiment contains a distinct effect on a chemical reaction making each effect on a chemical reaction mutually exclusive. Therefore if the terms promoting, encouraging, fostering, assisting, aiding, advancing, cultivating, supporting, or otherwise participating can be used interchangeably, then the applicant should not elect a species. If the chemical reactions are mutually exclusive and determine an effect on a chemical reaction, the applicant should elect an embodiment in K1-K9. The applicant shall supply reasoning to support an election of species K or to support making the embodiments of K1-K9 generic.

 \underline{K} , Effect on chemical reaction (¶43):

Art Unit: 2829

- 1. Promoting
- 2. Encouraging
- 3. Fostering
- 4. Assisting
- 5. Aiding
- 6. Advancing
- 7. Cultivating
- 8. Supporting
- 9. Participating

If applicant elects a method, applicant is required under 35 U.S.C. 121 to elect a single disclosed species for prosecution on the merits to which the claims shall be restricted if no generic claim is finally held to be allowable. Currently, no claim is generic. An example of an embodiment is A1B1C2D1E1F1G1H1J1K1. This would be a CVD deposition using a reaction promoter gas where the reaction promoter gas is a material that is an inert, noble gas, such as Argon, to form a metal and conductive film, such as Aluminum using an organic precursor that is distributed during the gas phase where the reaction takes place in an IC HDP reactor and the reaction-promoter gas also creates a self-sustain sputtering and promotes the chemical reaction.

Applicant is advised that a reply to this requirement must include an identification of the species that is elected consonant with this requirement, and a listing of all claims readable thereon, including any claims subsequently added. An argument that a claim

Art Unit: 2829

is allowable or that all claims are generic is considered nonresponsive unless accompanied by an election.

Upon the allowance of a generic claim, applicant will be entitled to consideration of claims to additional species which are written in dependent form or otherwise include all the limitations of an allowed generic claim as provided by 37 CFR 1.141. If claims are added after the election, applicant must indicate which are readable upon the elected species. MPEP § 809.02(a).

Should applicant traverse on the ground that the species are not patentably distinct, applicant should submit evidence or identify such evidence now of record showing the species to be obvious variants or clearly admit on the record that this is the case. In either instance, if the examiner finds one of the inventions unpatentable over the prior art, the evidence or admission may be used in a rejection under 35 U.S.C. 103(a) of the other invention.

A telephone call was made to Charles Brantley on 8/26/03 to request an oral election to the above restriction requirement, but did not result in an election being made.

Applicant is advised that the reply to this requirement to be complete must include an election of the invention to be examined even though the requirement is traversed (37 CFR 1.143).

Applicant is reminded that upon the cancellation of claims to a non-elected invention, the inventorship must be amended in compliance with 37 CFR 1.48(b) if one or more of the currently named inventors is no longer an inventor of at least one claim

Application/Control Number: 09/825,611 Page 9

Art Unit: 2829

remaining in the application. Any amendment of inventorship must be accompanied by a request under 37 CFR 1.48(b) and by the fee required under 37 CFR 1.17(i).

Conclusion

Any inquiry of a general nature or relating to the status of this application should be directed to the Group Receptionist whose telephone number is (703) 308-0957. See MPEP 203.08.

Any inquiry concerning this communication from the examiner should be directed to Lisa Kilday whose telephone number is (703) 306-5728. If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Kamand Cuneo, can be reached on (703) 308-1233. The fax number for the group is (703) 305-3432. MPEP 502.01 contains instructions regarding procedures used in submitting responses by facsimile transmission.

Lisa Kilday

LAK

9/4/03